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APPLICATION NO.	FIL	ING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/988,559	11/20/2001		Kenya Wada	216202US3	8756	
40575	7590	05/19/2004		EXAM	EXAMINER	
KCO LAW P.L.L.C.				HASSANZAD	HASSANZADEH, PARVIZ	
	P. O. BOX 220472 CHANTILLY, VA 20153-0472			ART UNIT	PAPER NUMBER	
	.,			1763		
				DATE MAILED: 05/19/2004		

Please find below and/or attached an Office communication concerning this application or proceeding.

			.A
	Application No.	Applicant(s)	
Advisory Action	09/988,559	WADA ET AL.	
Advisory Action	Examiner	Art Unit	
	Parviz Hassanzadeh	1763	
The MAILING DATE of this communication appe	ears on the cover sheet with the c	orrespondence add	ress
THE REPLY FILED 05 May 2004 FAILS TO PLACE THI Therefore, further action by the applicant is required to a final rejection under 37 CFR 1.113 may only be either: (1) condition for allowance; (2) a timely filed Notice of Appea Examination (RCE) in compliance with 37 CFR 1.114.	oid abandonment of this application) a timely filed amendment whicl	ation. A proper reply n places the applica	y to a ition in
PERIOD FOR RE	EPLY [check either a) or b)]		
a) The period for reply expiresmonths from the mailin	-		
b) The period for reply expires on: (1) the mailing date of this A no event, however, will the statutory period for reply expire I ONLY CHECK THIS BOX WHEN THE FIRST REPLY WAS 706.07(f).	ater than SIX MONTHS from the mailing	g date of the final rejecti	on.
Extensions of time may be obtained under 37 CFR 1.136(a). The fee have been filed is the date for purposes of determining the period of fee under 37 CFR 1.17(a) is calculated from: (1) the expiration date of (2) as set forth in (b) above, if checked. Any reply received by the Office timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.136(a). The fee have been filed in the period of th	of extension and the corresponding amo the shortened statutory period for reply ce later than three months after the mail	unt of the fee. The appropriate or the final	ropriate extension Office action; or
1. A Notice of Appeal was filed on Appellant's 37 CFR 1.192(a), or any extension thereof (37 CFR			
2. The proposed amendment(s) will not be entered be	ecause:		
(a) Ithey raise new issues that would require further	er consideration and/or search (s	see NOTE below);	
(b) they raise the issue of new matter (see Note b	pelow);	•	
(c) they are not deemed to place the application in issues for appeal; and/or	n better form for appeal by mate	rially reducing or sir	mplifying the
(d) they present additional claims without canceli	ng a corresponding number of fi	nally rejected claim	S.
NOTE: See Continuation Sheet.			
3. Applicant's reply has overcome the following reject	tion(s): all grounds of rejections.		
4. Newly proposed or amended claim(s) would canceling the non-allowable claim(s).	be allowable if submitted in a se	eparate, timely filed	amendment
5. ☐ The a) ☐ affidavit, b) ☐ exhibit, or c) ☐ request for application in condition for allowance because:	reconsideration has been consi	dered but does NO	T place the
6. The affidavit or exhibit will NOT be considered becaraised by the Examiner in the final rejection.	ause it is not directed SOLELY t	o issues which were	e newly
7. For purposes of Appeal, the proposed amendment explanation of how the new or amended claims we			and an
The status of the claim(s) is (or will be) as follows:			
Claim(s) allowed:			
Claim(s) objected to:			
Claim(s) rejected:			
Claim(s) withdrawn from consideration:			
8. The drawing correction filed on is a) appl	roved or b) disapproved by t	he Examiner.	
9. Note the attached Information Disclosure Statemer			

P. Haisongo del Parviz Hassanzadeh Primary Examiner Art Unit: 1763

10. Other: ____

Continuation of 2. NOTE: The currently amended method claim requires treating a surface of a substrate plate in an isolated environment such as a chamber which require further search and cosideration.